	Search Text	DBs
1	imprint near5 lithography	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB
2	(imprint near5 lithography) same mold\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
3	(imprint near5 lithography) same mold\$3 same transfer\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
4	8 and droplets	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
5	6 and droplets	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
6	156/230,232	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
7	(156/230,232).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
8	(156/230,232,235).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
9	(264/255,259).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
10	(264/488,494).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB